

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	442	barrier and poly and pt and tin	USPAT; EPO; JPO; DERWEN; T; IBM_TD; B	2002/12/04 10:36
2	BRS	L2	33	1 and (oxygen adj diffusion)	USPAT; EPO; JPO; DERWEN; T; IBM_TD; B	2002/12/04 10:37

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	16	arc and sion and (index adj refraction)	USPAT; EPO; JPO; DERWEN; T; IBM_TD B	2002/12/04 10:13

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	55	silicon and photolithography and arc and (etch adj selectivity)	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2002/12/04 09:31